2026/03/13
Distributed by FUJIFILM Wako Pure Chemical Corporation
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Code No.20-2000

SPECIFICATION

(Trimethylsilyl)methylmagnesium Chloride, Tetrahydrofuran Solution (abt. 1mol/L)

for Organic Synthesis

REQUIREMENT	SPECIFICATION
Appearance	to pass test
Density (20℃)	under investigation
Concentration	0.8～1.2mol/L

established on 2019/03/11